



Metal-Insulator Transition in disordered two-dimensional (2d) Fermi liquid

(Anderson transition in the presence of $e-e$ interactions)

(no “Mottness”)

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Alex Punnoose & A.F. ,
Phys. Rev. Lett. **88** (2002);
Science **310**, 429 (2005);

S.Anissimova, S Kravchenko,
AP, AF and TM Klapwijk,
Nature Physics, **3** (2007).

thanks to Vladimir Pudalov from
the Lebedev Physics Institute of RAS

□ scaling ideas in the Metal-Insulator Transition (MIT):
why “in two-dimensions, there is no **true** metallic behavior”

□ transport in low and high mobility 2d systems:
why **high** mobility systems are so interesting?

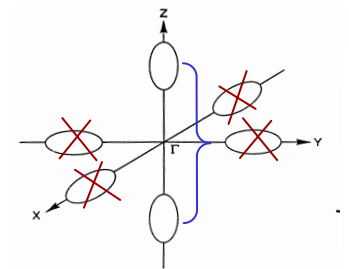
→ □ why: “highly controversial issue of the nature of **apparent** MIT in 2d”

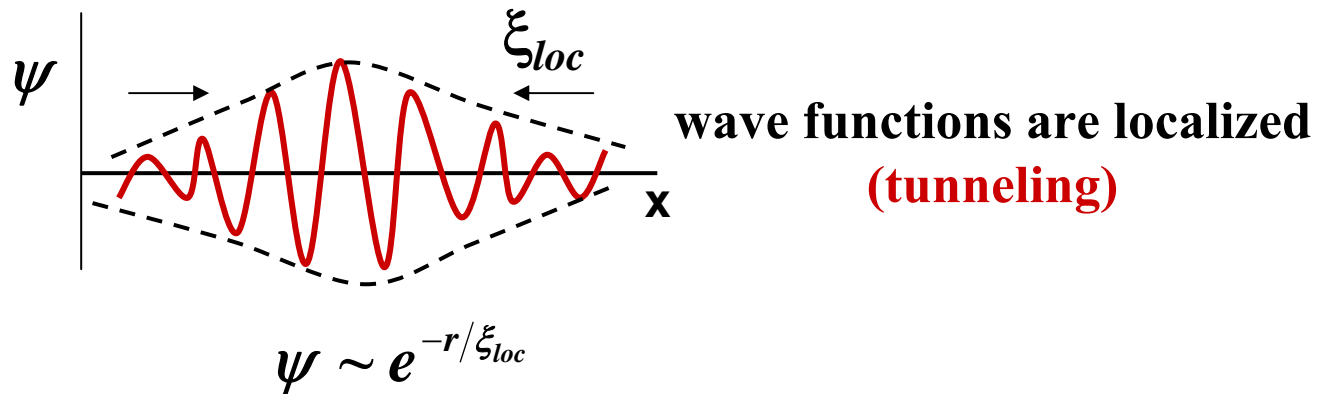
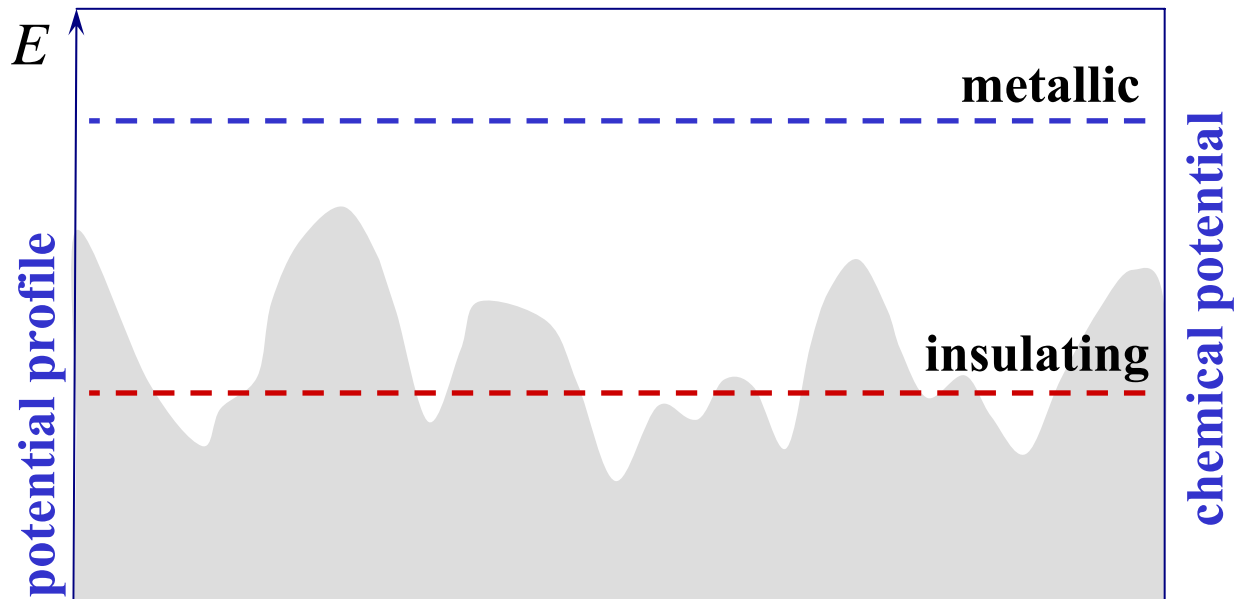
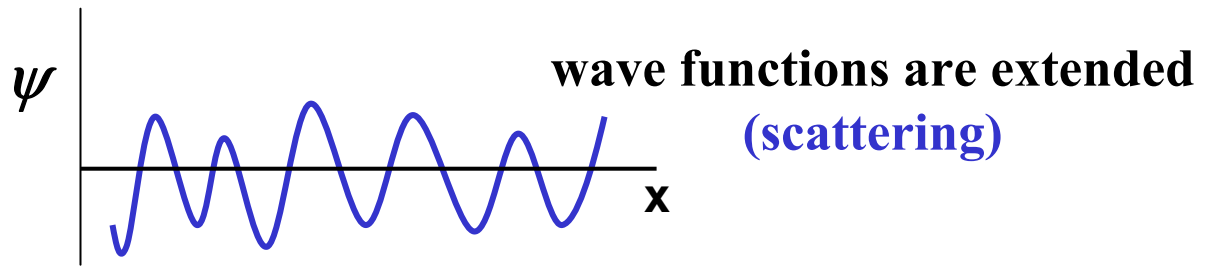
□ disordered Fermi-liquid, the **two parameter** RG scheme

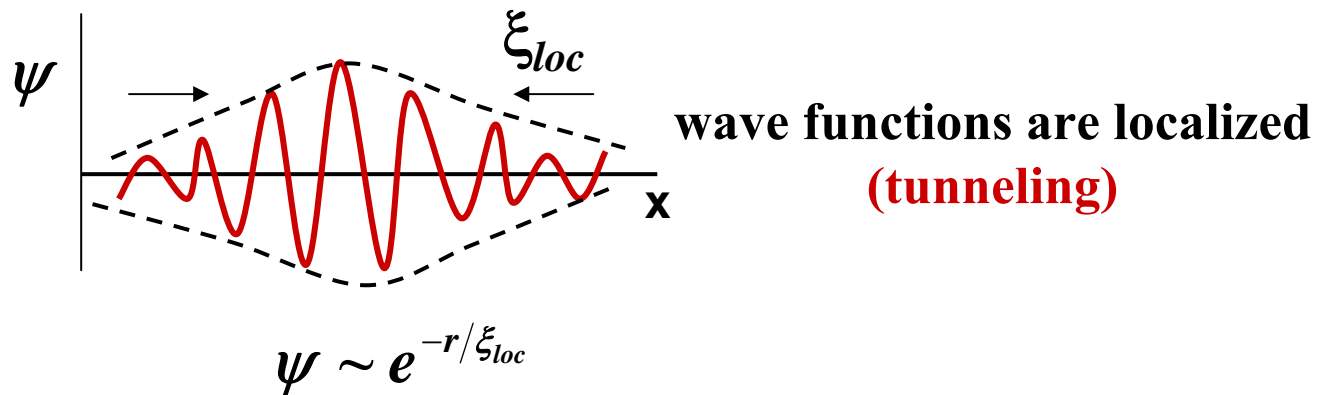
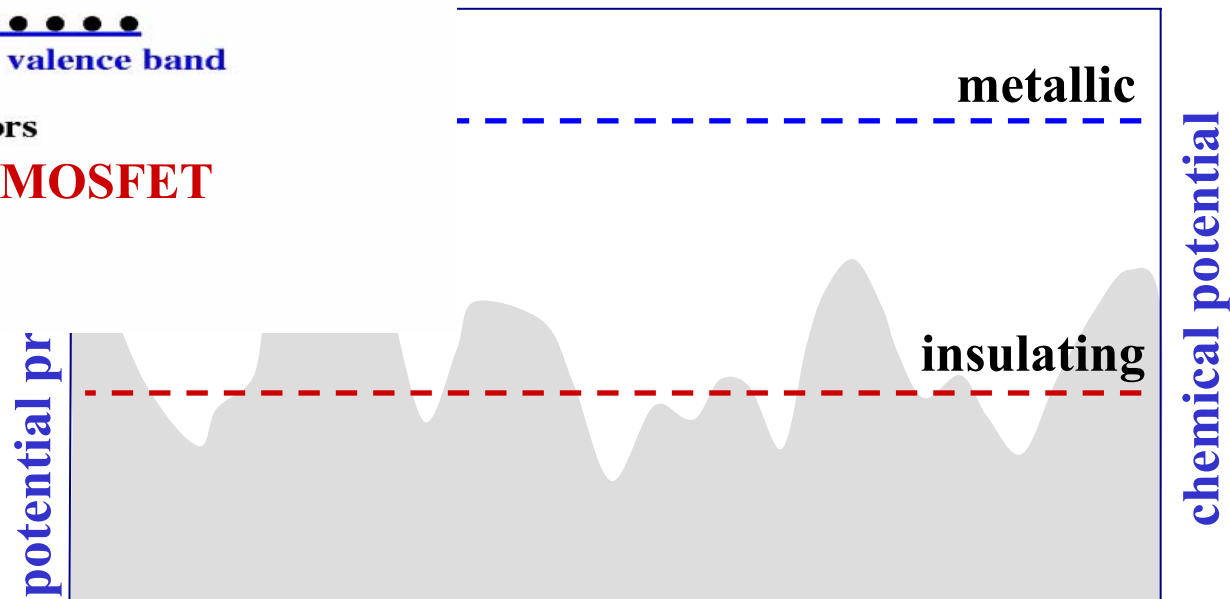
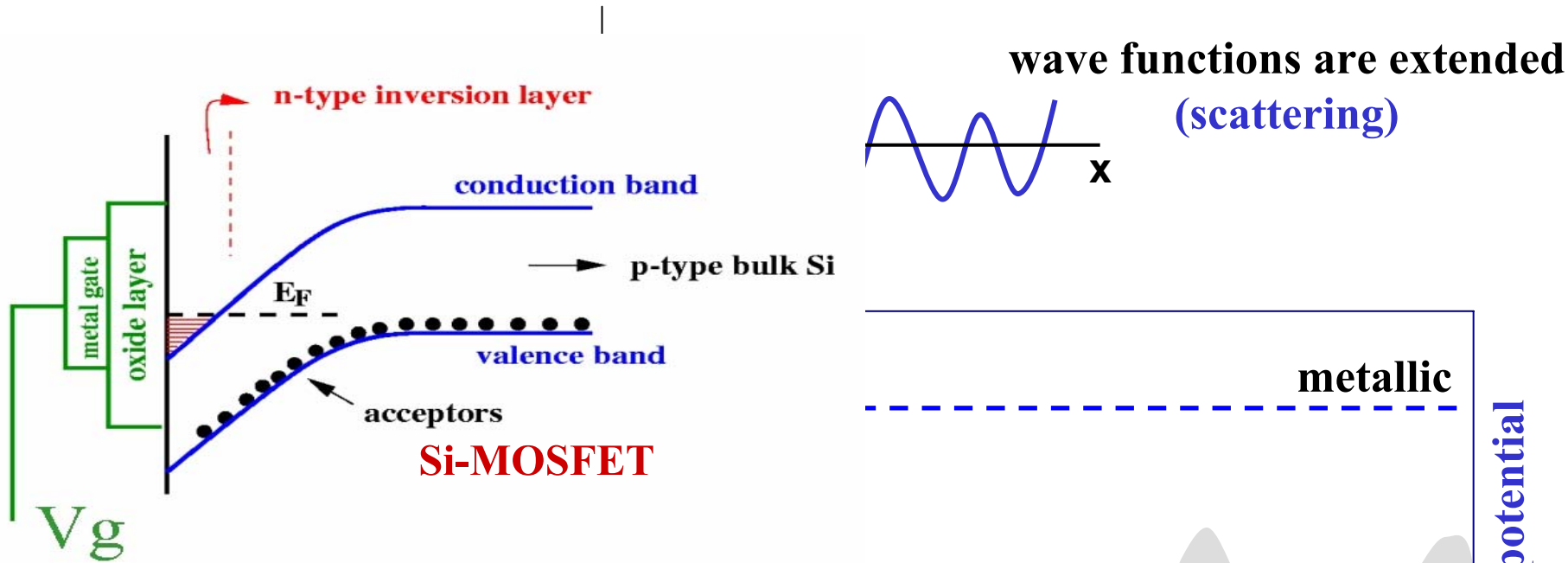
□ **valleys** (flavors) in Si-MOSFET; **large- n_v** limit

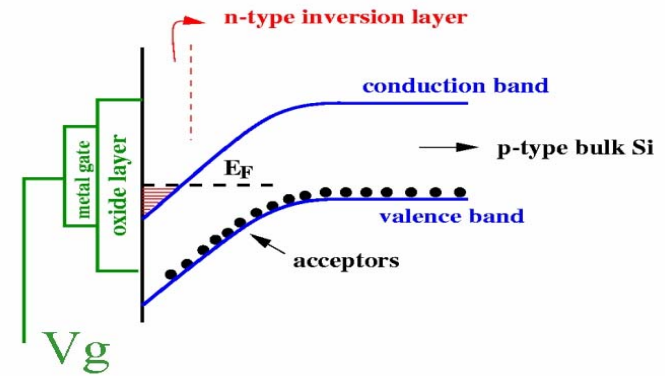
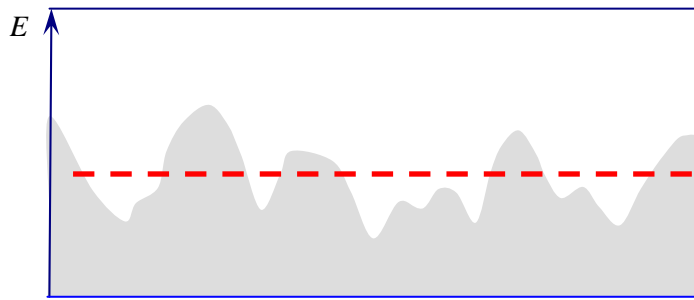
□ phase diagram in the **two-loop** solution

→ □ experimental confirmation (fan-like magnetoresistance; **flow diagram**)

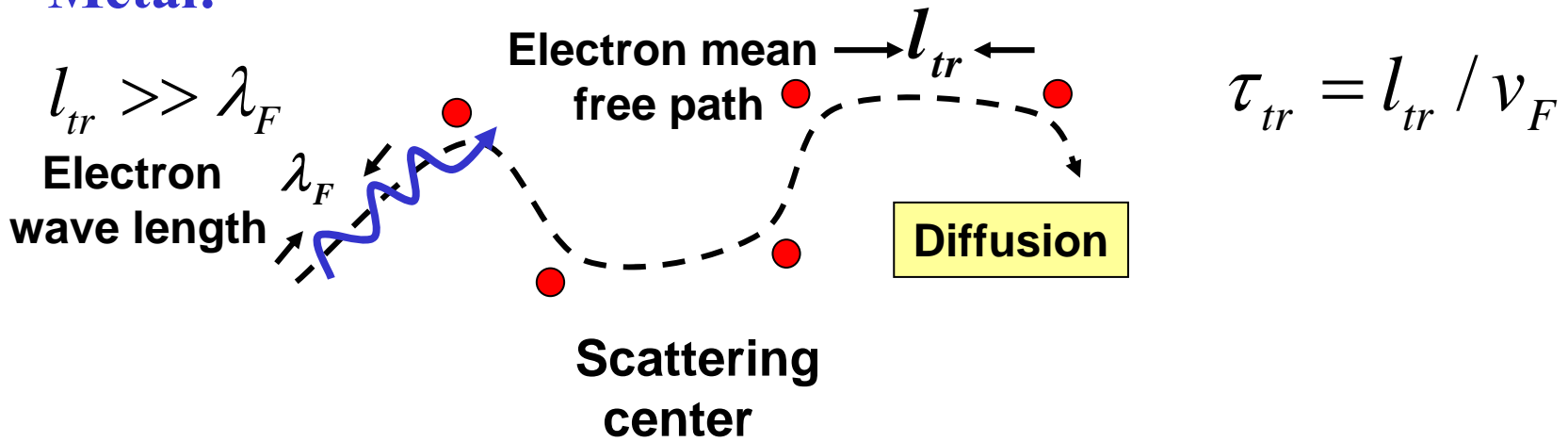








Metal:



Transition: $p_F l_{tr} \sim E_F \tau_{tr} \sim \hbar$ Ioffe – Regel ; Mott

Insulator: area of quantum physics; ξ_{loc}

Nature of the M-I transition?
experiment? everything was smeared by a finite temperature

**Nature of the
M-I transition**

Absence of Diffusion in Certain Random Lattices

P. W. ANDERSON

Bell Telephone Laboratories, Murray Hill, New Jersey

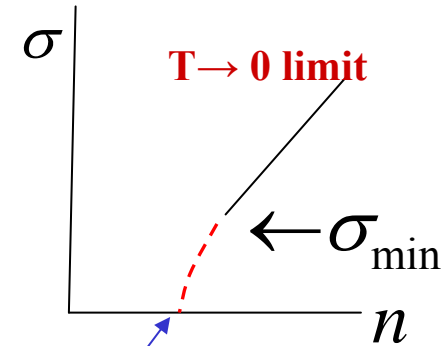
M-I Transition at zero temperature in 3d
(σ denotes conductivity, n – electron density)

**Anderson localization:
importance of large scales**

$$\xi_{loc} \gg l_{tr}$$

→ scaling;

What is the role of dimension?

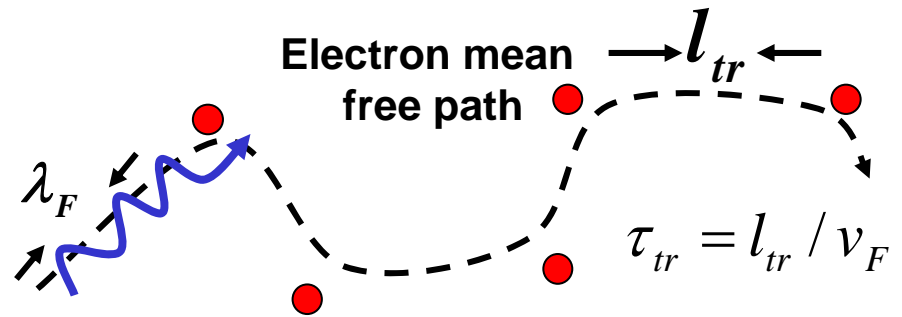


Quantum Critical Point:

$$\xi_{loc} \rightarrow \infty$$

$$\sigma_{Drude} = \frac{ne^2\tau_{tr}}{m}$$

Electron
wave length



M-I Transition:

$$p_F l_{tr} \sim E_F \tau_{tr} \sim \hbar$$

Ioffe – Regel criterion

$$\sigma_{d=2} = e^2 \frac{(p_F^2 / 2\pi\hbar^2)(l_{tr} / v_F)}{m} \sim e^2 / (2\pi\hbar) ; 2\pi\hbar / e^2 \approx 25.8 \text{ k}\Omega$$

What makes **d=2** so special?

$$R_{\text{Ohm's Law}} = \frac{L}{\sigma_d L^{d-1}} = \frac{L^{2-d}}{\sigma_d}$$

in d=2 conductivity coincides with **conductance** (i.e., R^{-1}).

Message from d=2:

forget about conductivity – study **conductance** of a “cubic”
sample measured in the universal unit

$$\mathbf{g} = R_{\text{esistance}}^{-1} / (e^2 / h)$$

Scaling ideas in transport : Thouless (74,77); Abrahams, Anderson, Licciardello, Ramakrishnan (79); F. Wegner (79).

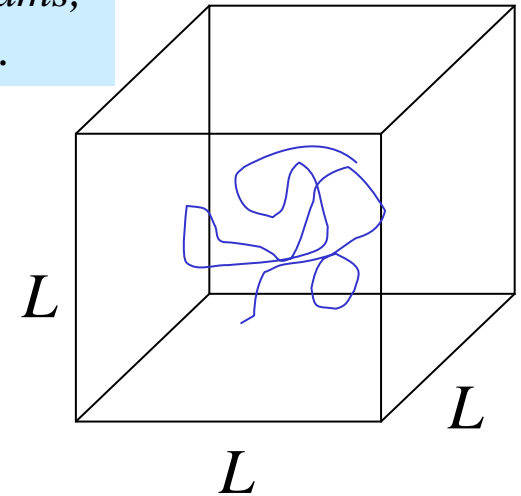
Renormalization Group transformation:
 increasing of the blocks size from l_{tr} to L

dimension $d=2$ is of special importance;
 the geometrical factor in the Ohm's law,
 $g = \sigma L^{d-2} / (e^2 / h)$, disappears at $d=2$.

$$\frac{dg}{d\xi} = \beta(g) ; \xi = \ln (L / l_{tr}).$$

this equation has a very **specific form**: $\beta(g; \cancel{L}, \cancel{l_{tr}})$

M-I transition: $\beta(g = g_{crit}) = 0$.



$g(L)$ –
 dimensionless
conductance
of a sample
 of the size L :
 $g(L) = R^{-1}(L) / (e^2 / h)$

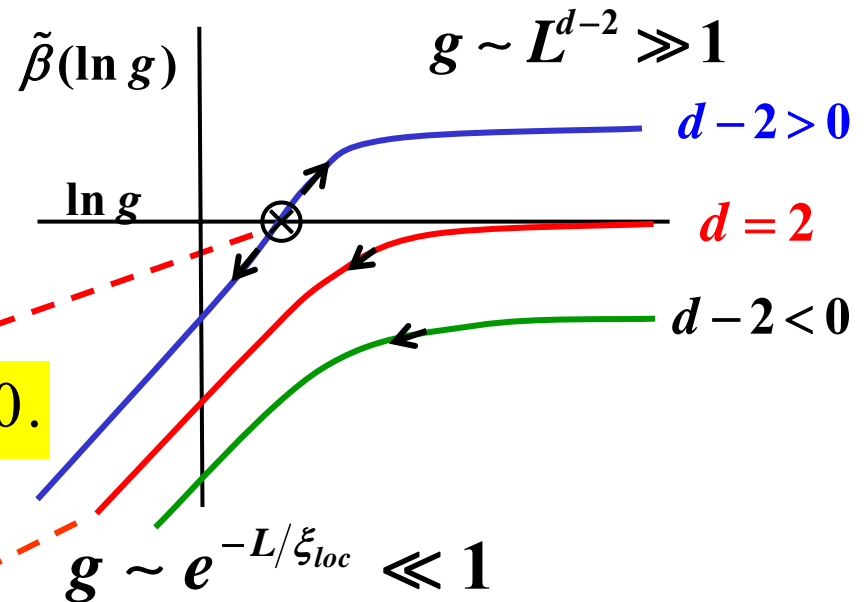
does not depend **explicitly** on L

Origin of the common believe that “in two-dimensions, there is no **true** metallic behavior”

Abrahams, Anderson, Licciardello, Ramakrishnan (79)

$$\frac{d \ln g}{d \xi} = \tilde{\beta}(\ln g) ; \quad \xi = \ln(L / l_{tr}).$$

one-parameter scaling
theory of the MIT:
a competition between
the Ohm's law factor L^{d-2}
and the QM interference



$3d : \beta(g_{crit}) = 0.$

2d electrons
eventually become localized

$$\ln(1/T\tau_{tr}) > g(l_{tr})$$

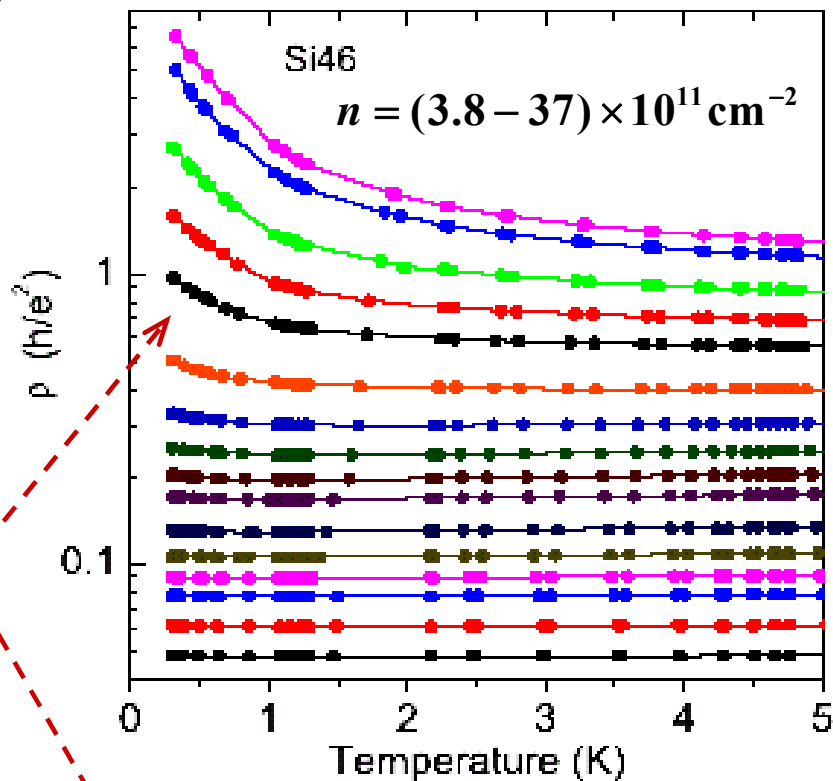
scale is controlled by the temperature

here conductance g is assumed to be
the only relevant scaling parameter

Si-MOSFET

low mobility $\mu=1,500\text{cm}^2/\text{Vs}$

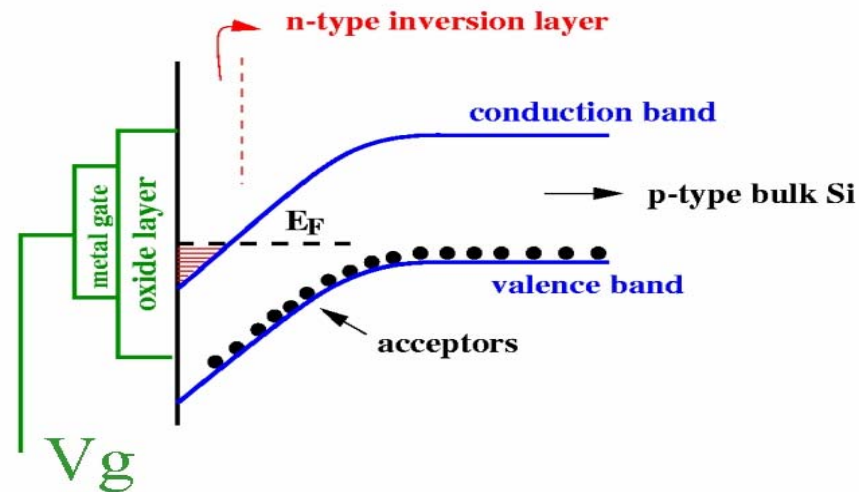
ρ , not σ !



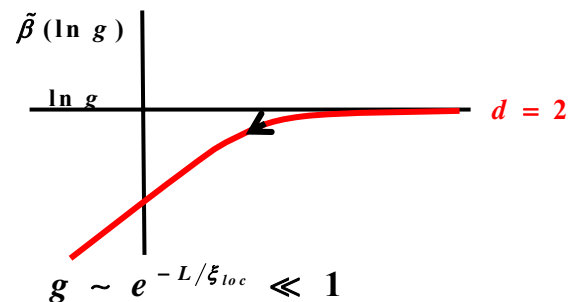
2D electron states
 eventually become localized

$$\ln(1/T\tau_{tr}) > g(l_{tr}) = 1/\rho$$

2DEG in Si-MOSFETs



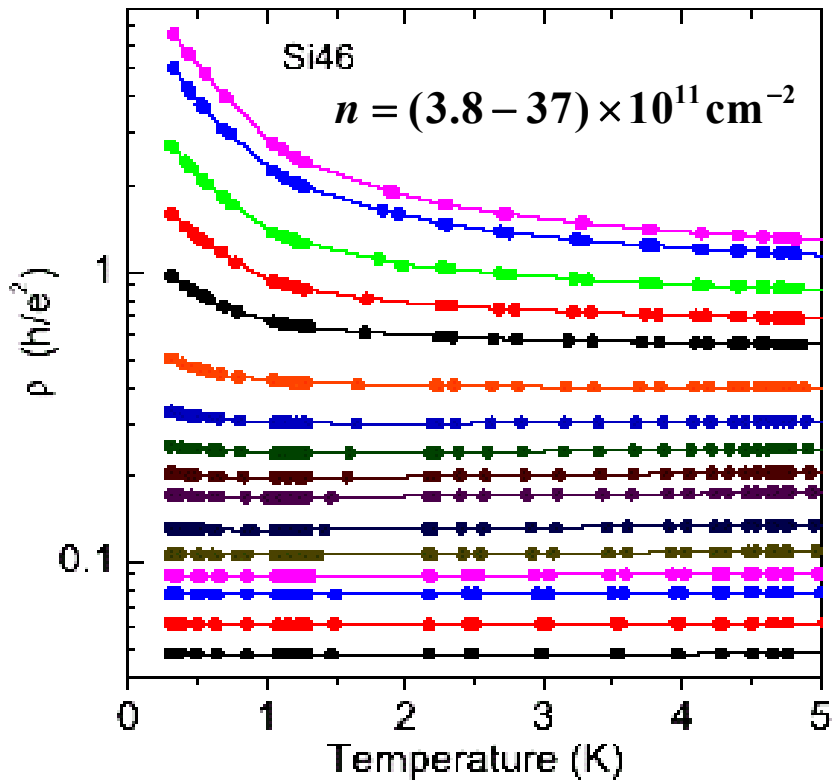
Energy $\left(\frac{k_z^2}{2m_z} \right)$ is quantized in the z-direction



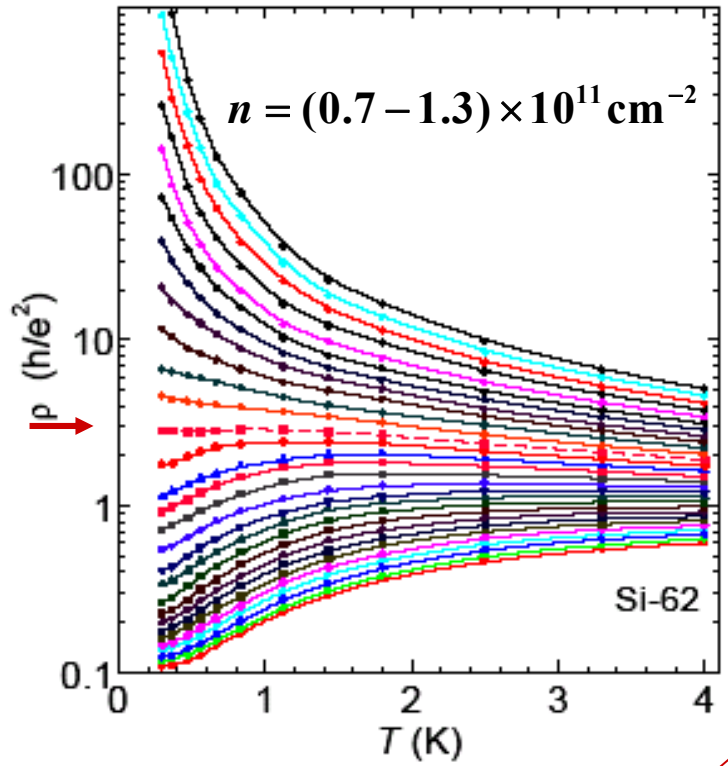
apparent Metal Insulator Transition in 2d (Si-MOSFET)

S. Kravchenko et al., 1994 (Pudalov's group)

low mobility $\mu=1,500 \text{ cm}^2/\text{Vs}$



high mobility $\mu=39,000 \text{ cm}^2/\text{Vs}$



2D electron systems
eventually become insulating

$$\ln(1/T\tau) > 1/\rho$$

$$n_c \sim 10^{11} \text{ cm}^{-2} \quad \rho_c \sim \frac{\pi h}{e^2}$$

apparent MIT transition

apparent:

1 clearly seen or understood: *It was apparent for all of us*

2 appearing but not necessary true or genuine: *the apparent cause but not the real one*

A.S. Hornby, Oxford Student's Dictionary of Current English

what is specific in high mobility samples?

$$\mu \propto \sigma / n$$

$$\mu^{-1} = \frac{m}{e} \tau_{tr}^{-1}$$

at the metal-insulator

transition:

$$l_{tr} \sim \lambda \Rightarrow E_F \sim 1 / \tau_{tr}$$

the higher mobility, the **lower**
density can be reached **remaining**
still in the metallic phase

$$E_F \propto n$$

MOSFETs: $n = 10^{11} \text{ cm}^{-2}$

$$E_F = \frac{\pi \hbar^2 n}{2m} \approx 7 \text{ K}$$

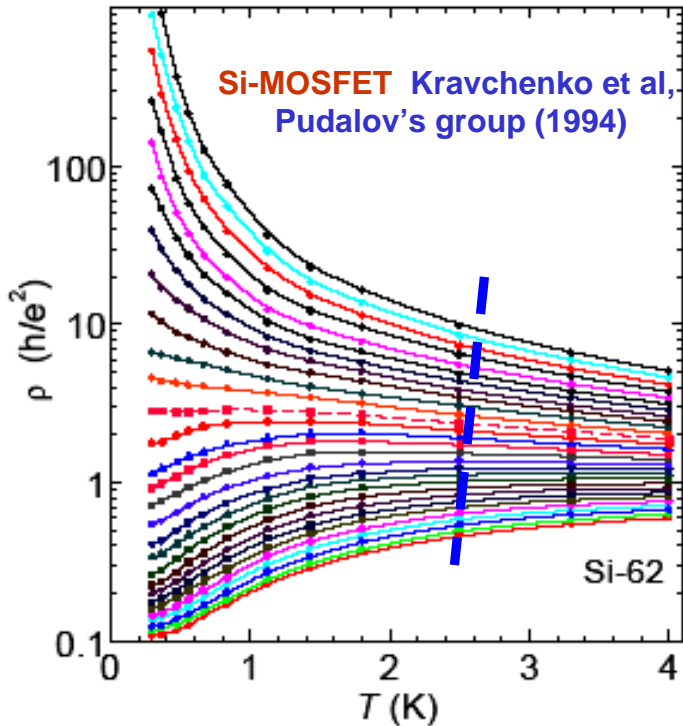
$$r_s \equiv \frac{E_{ee}}{E_F} \approx 10$$

$$E_{ee} = \frac{e^2}{\epsilon} (\pi n)^{1/2} \approx 70 \text{ K}$$

naïve and incorrect!

**is the phenomenon universal?
Si-MOSFET, p-GaAs, n-GaAs**

$$1/\tau = (e/m)\mu^{-1}$$

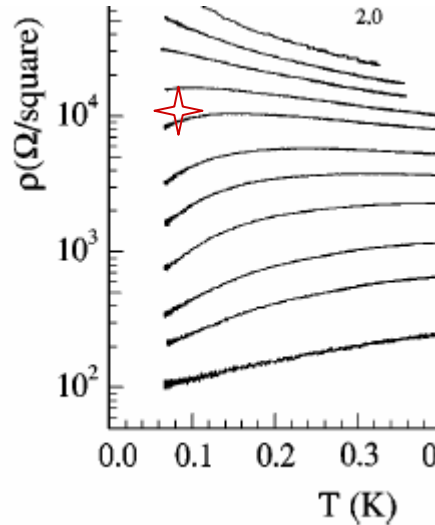


$$1/\tau_{tr} \sim 2 \div 3K$$

$$\text{mobility } \mu \sim 3 \times 10^4 \text{ cm}^2 / Vs$$

$$[R_{\max}(T) - R(0)]/R(0) \sim 7 \quad !$$

$$r_s \sim 10$$



p-GaAs Noh et al,
Dan Tsui's group (2003)

$$[R_{\max}(T) - R(0)]/R(0) \sim 2$$

$$r_s > 20$$

FIG. 2. ρ vs T for $p = 3.2, 2.2, 1.7, 1.2, 0.9, 0.7, 0.5, 0.4, 0.3, 0.23,$ and $0.15 \times 10^{10} \text{ cm}^{-2}$ from the bottom. The inset shows ρ

$$\mu \sim 3 \times 10^5 \text{ cm}^2 / Vs \quad 1/\tau_{tr} \approx 0.1K$$

n-GaAs Lilly et al,
Eisenstein's group (2003)

$$R_{\max}(T) - R(0) \sim 25\% \quad r_s \sim 10$$

Referee : “ *highly controversial* issue of the nature of *apparent* MIT in two-dimensions.”

p-GaAs

1. Ultra high mobility: diffusive regime is hard to reach; $1/\tau \sim 100$ mK
2. Long range scattering: transport time \gg quantum life time (quasiclassical motion)
3. Very low density: large- r_s , but also effects of non-degeneracy at $T \sim E_F$
4. Theoretical possibilities: percolation, screening (but also WC, stripes, bubbles, etc)

At low enough temperatures, diffusive regime will unavoidably be reached, but **at finite T, one is observing a crossover – not the MIT (a la Anderson)**.

Si-MOSFET: advantages

1. Moderately “high” mobility: diffusive window $T < 1/\tau_{tr} < E_F$; $1/\tau_{tr} = 2-3$ K
2. Short range scattering: transport time is comparable to quantum life time (quantum-mechanical scattering)
3. E-e nteraction: **nearly optimal value of the bare values of the interaction**
4. Multi-valley system: **effectiveness** of the fluctuations induced by e-e interactions **is enhanced**

$$(1/\epsilon_F \tau_{tr}) \ll 1$$

“Probing the ...Quantum Phase Transition in the ...localization”

Phys. Rev. Lett. 84, 1567 (2000)

Amsterdam University group

InGaAs/InP
mobility $\mu = 1.6 \times 10^4 \text{ cm}^2 / \text{Vs}$



Si - MOSFET mobility
 $\mu \sim 3 \times 10^4 \text{ cm}^2 / \text{Vs}$

relatively

Because of the short range random alloy potential scattering, the low mobility $\text{In}_x\text{Ga}_{1-x}\text{As}/\text{InP}$ structure has proven to be exceptionally important for studying scaling phenomena. This produces a wide range in T where the transport is dominated by Anderson (de)localization effects. This is in sharp contrast to high mobility GaAs/ $\text{Al}_x\text{Ga}_{1-x}\text{As}$ heterostructures where the long range potential fluctuations dramatically complicate the observability of the critical phenomenon, given the limitations of the experiment [3,4].

$T \sim 0.1 \div 5K$

non-monotonic $\rho(T)$ in a high mobility sample

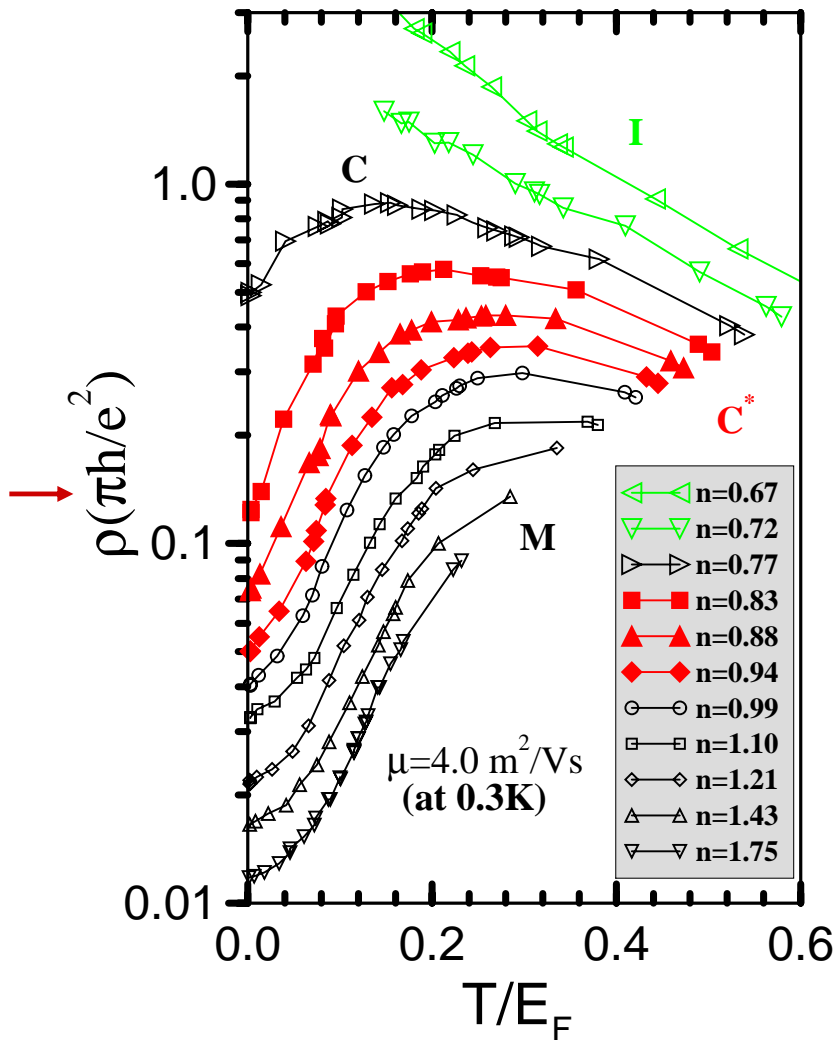
(first most important slide)

the regions of my interest (C and C*):
strongly interacting electrons in the
diffusive regime

$$T < \hbar / \tau \leq E_F$$

**A universal picture with a
single parameter scaling?**

$$\frac{d\rho}{d\xi} = \beta_{\infty}(\rho)$$



Pudalov, et al., ('98)

**similar data but
replotted as T/E_F**

starting point: **disordered Fermi-Liquid;**
in Si-MOSFET $e-e$ interaction effectively is not too strong!

$$\text{MOSFETs: } n = 10^{11} \text{ cm}^{-2} \quad r_s \equiv \frac{E_{ee}}{E_F} \simeq 10$$

no noticeable anomalies on the metallic side of the MI transition!
Shubnikov oscillations, Hall coefficient,
weak localization corrections

$$g^*/g_0 = \frac{1}{1 + F_0^\sigma} \approx 1.5 \quad m^*/m \approx 3$$

singlet amplitude γ_1
 is **universal "1"**
 after screening $\beta_{\infty}(\rho)$

warning: in the following
 the case of Coulomb interaction only;
 no free-electron limit in RG equations.

"triplet" amplitude γ_2
 $1 + \gamma_2 = \frac{1}{1 + F_0^\sigma}$

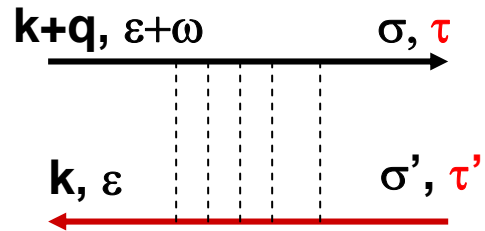
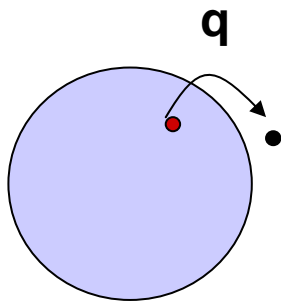
this is a driving force of
MIT transition in 2D !

low energy physics is described by two-particle propagators
 (rather than single-particle Green's functions)
 fluctuations of charge, spin and valley **densities**

**Disorder-averaged
two-particle propagators**

semiconductors: spin + valleys

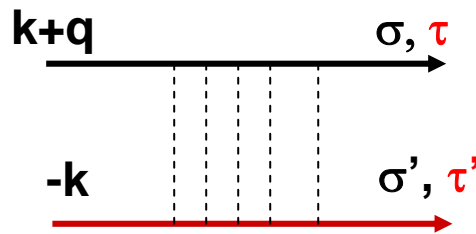
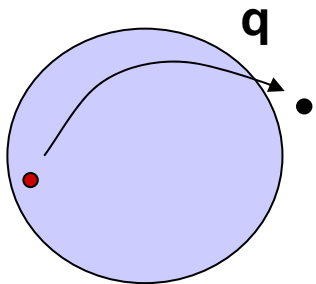
$$\left(\frac{\partial}{\partial t} - \nabla^2 \right)$$



$$\approx \frac{1}{Dq^2 - i\omega}$$

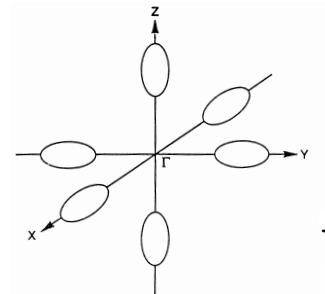
**particle-hole propagator
(diffuson)**

**diffusive
pole**



$$\approx \frac{1}{Dq^2 - i\omega}$$

**particle-particle propagator
(cooperon)**



Elements of disordered Fermi-Liquid :

leading order in $\frac{1}{\mathcal{E}_F \tau_{tr}} \ll 1$

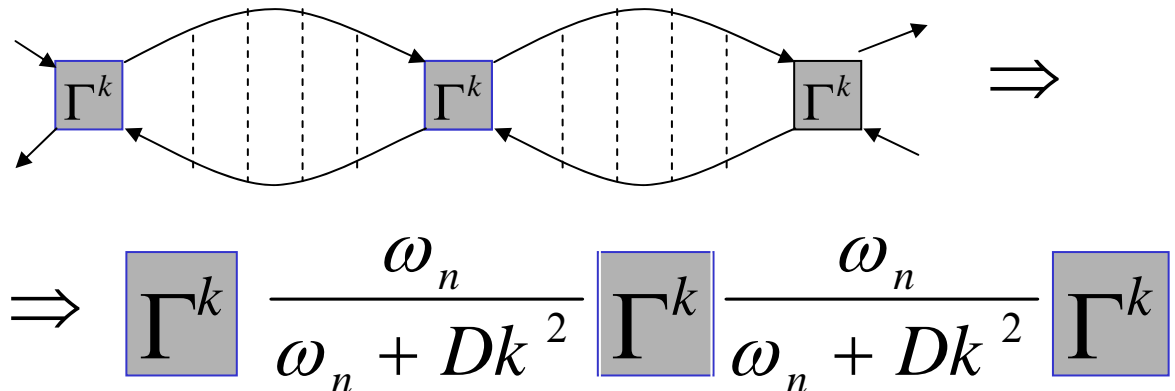
$\tau_{tr}^{-1} \gg \varepsilon, T$ (plane waves are not eigenstates anymore)

multiple rescattering of pairs of quasiparticles
(each time two into two) should be modified by **diffusion**:

$$\left(\frac{\omega}{\omega - \vec{v} \cdot \vec{k}} \right)_{clean} \Rightarrow \left(\frac{\omega_n}{\omega_n + Dk^2} \right)_{disorder}$$

Static amplitudes remain unchanged in the leading order $1/\mathcal{E}_F \tau_{tr} \ll 1$

dynamic amplitude of scattering in the particle-hole channel; only $l=0$ harmonic is relevant



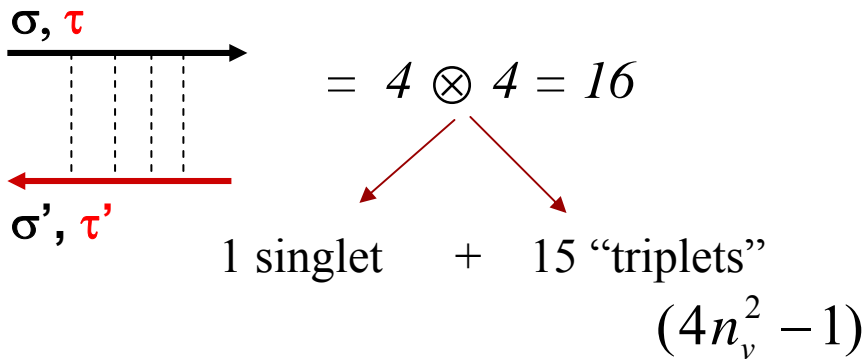
valley in high-mobility Si-MOSFET is a good quantum number (second most important slide)

➤ quantum numbers (pseudo spin)

$$|\sigma, \tau\rangle \equiv \left| \left\{ \uparrow \downarrow \right\}, \left\{ \pm \right\} \right\rangle$$

2 spin \otimes 2 valleys = 4 states

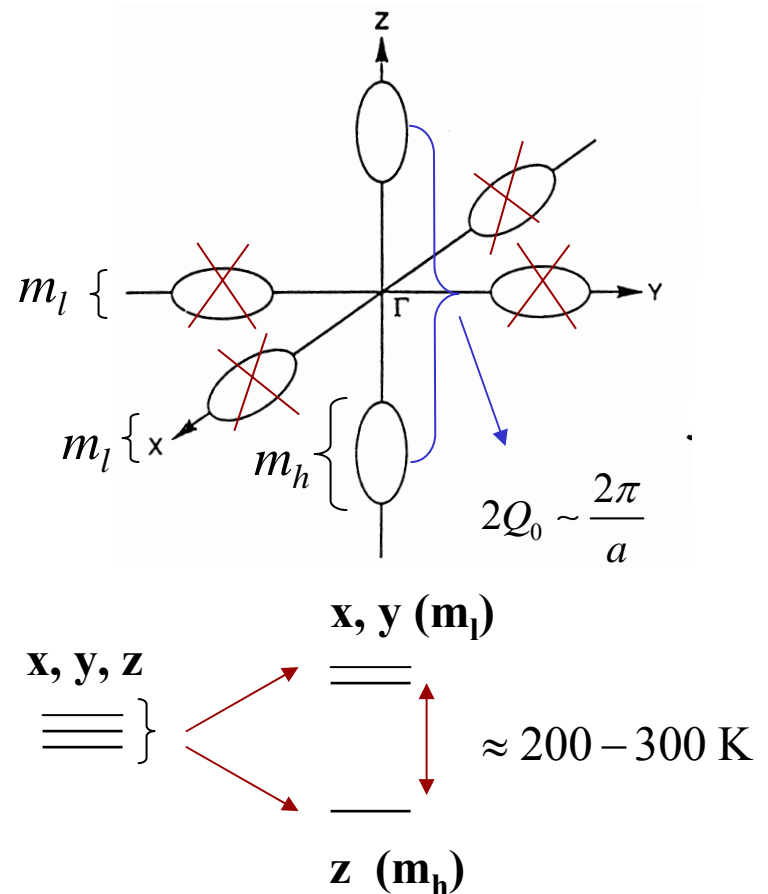
➤ total number of electron-hole states



**Specifics of high mobility samples:
no inter-valley scattering**

$$k_z \ll Q_0 !$$

Lifting of the valley degeneracy in a (001) layer



energy is quantized in the z-direction
(perpendicular to the interface)

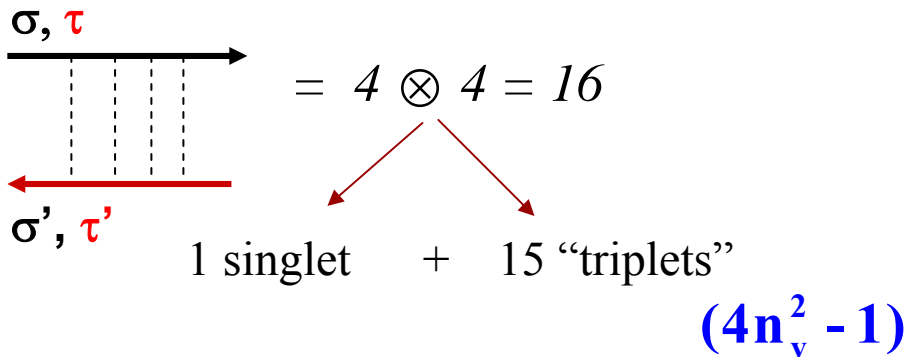
valley in high-mobility Si-MOSFET is a good quantum number

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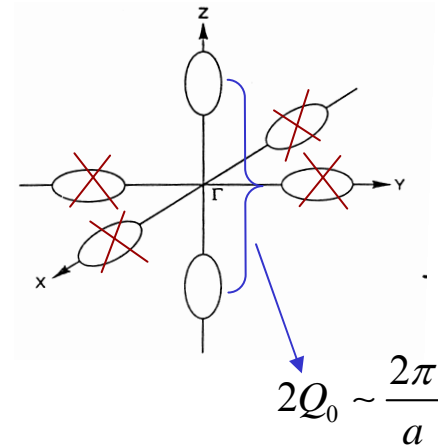
$$2 \text{ spin} \otimes 2 \text{ valleys} = 4 \text{ states}$$

➤ total number of electron-hole states



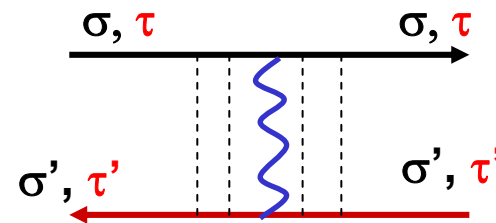
**Specifics of high mobility samples:
no intervalley scattering**

$$k_z \ll Q_0 !$$



e-e interaction: couples all spin/valleys species together but does not mix them (!)

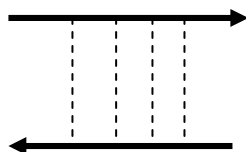
valleys: much more fluctuation degrees of freedom are involved



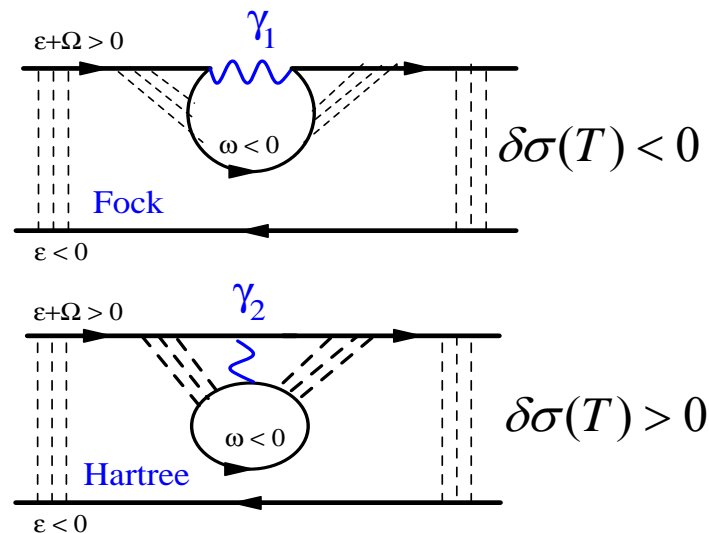
beyond the disordered Fermi-liquid: interplay of the electron-electron interactions and disorder

1) *e-e* interactions activate virtual transitions; because of the slowness (softness) of the diffusion modes this leads to non-analytical in temperature corrections to the resistances

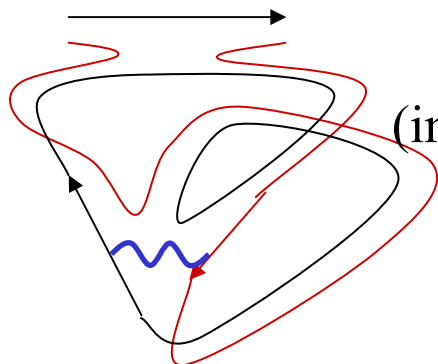
Altshuler, Aronov (79); Altshuler, Aronov and Lee (80)



$$\sim \frac{1}{Dq^2 - i\omega}$$



two contributions of opposite signs (a la Hartree-Fock); "Hartree" contribution is anti-localizing (eventually causes the MI transition in 2D)



2) a source of non-linearity (in this example 3 modes to 1)

3) renormalization of the *e-e* interaction amplitudes

**a unified scheme which includes:
disorder and e-e interaction,
charge, spin (and valleys)
RG-flow**

non-linear σ - model with e - e interactions

A. F. (83)

$$S[Q] = \frac{\pi V}{4} \int \text{Tr} \left[D(\vec{\nabla} Q)^2 - 4z \text{Tr}(\hat{\varepsilon} Q) + Q(\hat{\Gamma}_s + \hat{\Gamma}_t + \hat{\Gamma}_c)Q \right] d^2 r$$

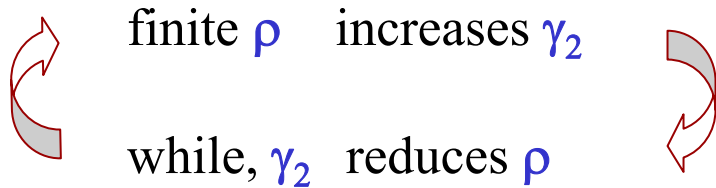
$$Q_{nm}^{\alpha\beta ij} \quad \text{Tr} Q = 0 \quad Q^2 = I$$

parameter z describes renormalization of the DOS of the diffusion modes

1) RG flow \longrightarrow 2) physical quantities

Two parameter scaling

AF (1983-84)



to all orders in e-e interactions

$$\frac{d \ln \rho}{\rho d \xi} = \left[n_v + 1 - \overbrace{(4n_v^2 - 1) \left(\frac{1 + \gamma_2}{\gamma_2} \ln(1 + \gamma_2) - 1 \right)}^{\text{“triplet”}} \right]$$

cooperon *singlet* *“triplet”*

$$\frac{d \gamma_2}{\rho d \xi} = \frac{(1 + \gamma_2)^2}{2}$$

$$\xi = \ln(1 / T \tau_{tr}) , \quad T \tau_{tr} \ll 1$$

RG-equations has been adjusted for n_v valleys by
A.Punnoose and AF, PRL (2002) ;

Owing to the factor $(4n_v^2 - 1)$ anti-localization trend
increases dramatically!

the interplay of disorder (i.e. ρ)
and interaction γ_2 changes the trend
and gives non-monotonic resistance

singlet amplitude
is **universal “1”** after screening

$$\beta_{\infty}(\rho)$$

Solutions of the RG-equations:

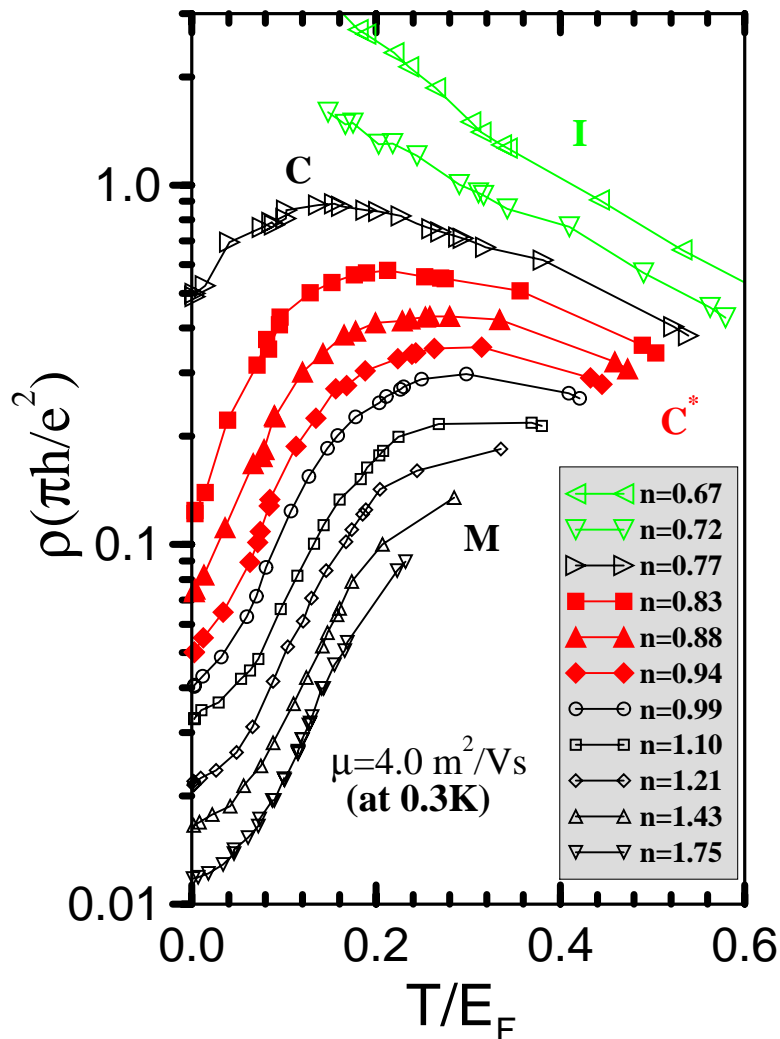
a series of non-monotonic curves
 $\rho(T)$.

After rescaling the solutions are
described by a **single** curve

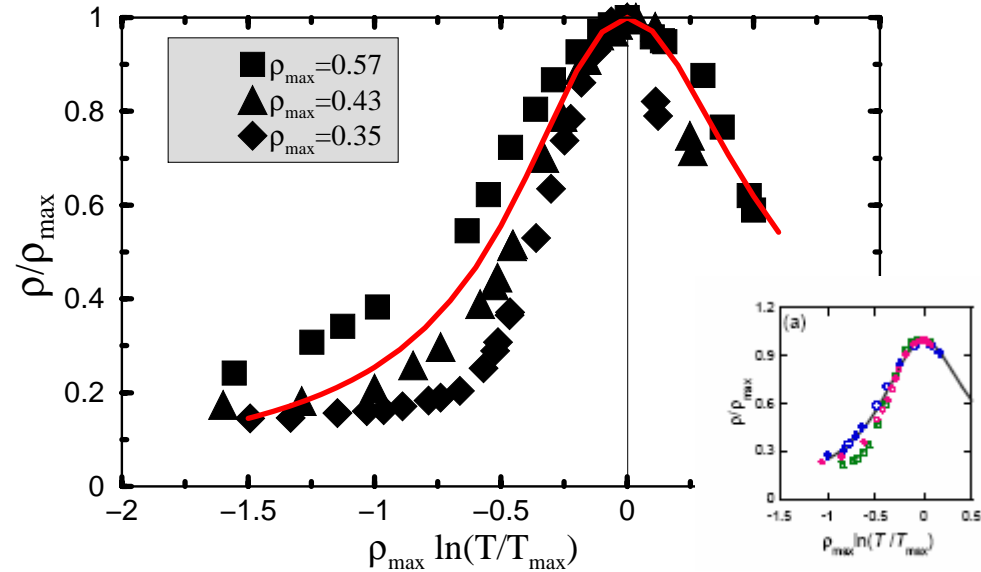
$$\rho(T) = \rho_{\max} \mathbf{R}(\eta)$$

$$\eta = \rho_{\max} \ln(T_{\max} / T)$$

Analysis of the region C^* in a high-mobility sample with RG for two valleys



Pudalov, et al., ('98)



Data from the region C^* in a high-mobility samples (Pudalov's and Klapwijk's)

- the drop of five times in $\rho(T)$ and its slowing down has been captured in the correct temperature interval

- **no adjustable parameters** are used

A.Punnoose and AF, PRL (2002)

S. Anissimova et al cond mat/0609181

**what is specific in high mobility MOSFET samples?
amount of degrees of freedom available for fluctuations!**

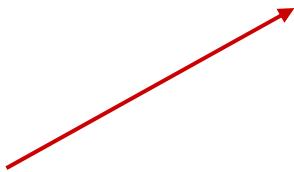
in-plane magnetic field: two valleys

$$\hbar / \tau > g \mu_B H_{\parallel} > kT$$

$$\frac{d\rho}{d\xi} = \rho^2 \left[n_v + 1 - (2n_v^2 - 1) \left(\frac{1 + \gamma_2}{\gamma_2} \ln(1 + \gamma_2) - 1 \right) \right]$$

instead of $(4n_v^2 - 1)$ only $(2n_v^2 - 1)$

at $T \sim 1K$ $\gamma_2 \approx 0.5 \div 0.7$



**is not enough for anti localization in the presence of magnetic field
at $T \sim 1K$ a magnetic field $\sim 1Tesla$ blocks the drop in the resistance;**

see [Burmistrov and Chtchelkatchev \(2008\)](#) for more accurate analysis

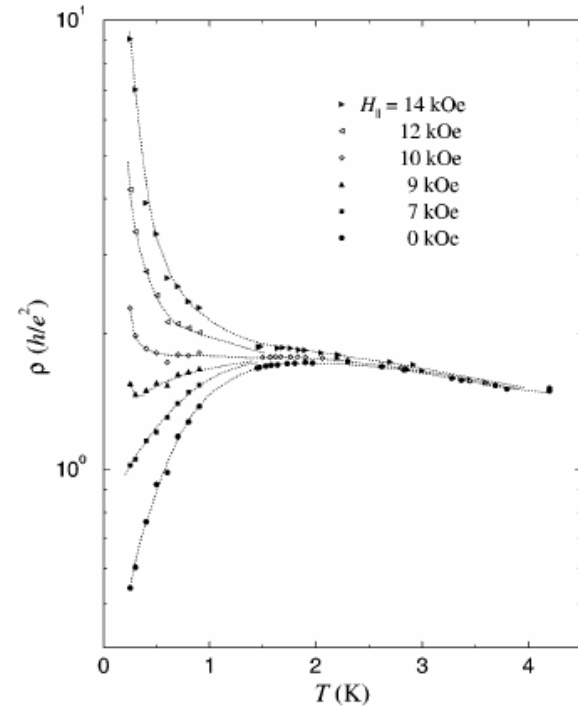


FIG. 4. Resistivity of sample 2 versus temperature in the absence of a field (bottom curve) and in five different parallel magnetic fields. The electron density corresponds to $\delta = 0.10$.

in-plane magnetic field

M.Sarachik group 1997-98

Two-parameter scaling: first lessons

Internal problem of the one loop theory:
divergence in the interaction amplitudes at a finite temperatures

$$\gamma_2(T^*) \rightarrow \infty$$

$$D_s(T^*) \rightarrow 0$$

spin diffusion coefficient

creation of localized moments and
two-stage route (1984) to the MIT transition
(first spins, next charges),
AF & Castellani, Di Castro, P.A Lee et al

- **for** $n_v = 2$ the theory is consistent down to $T^* \approx T_{\max} e^{-30000}$

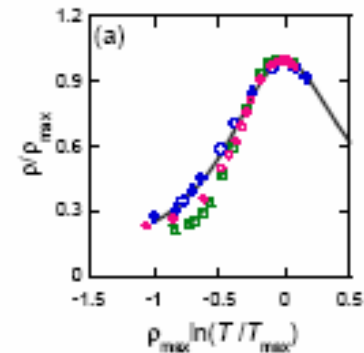
$$\ln(\ln 1/T^*) \sim (2n_v)^2$$

- in the limit $n_v \rightarrow \infty$ the theory is internally consistent including $T \rightarrow 0$

Two-parameter scaling

- **one-loop conclusion of the two-parameter scaling:**

for 2-valleys, the existence of the *Metal to Insulator* transition in 2d is (~~“apparently”~~) **logically unavoidable**, provided that the Anderson localization at strong disorder is undisputable



- Why two-loop?
because in one-loop the solutions after rescaling become a single curve.

$$\rho(T) = \rho_{\max} R(\eta)$$

$$\eta = \rho_{\max} \ln(T_{\max}/T)$$

Valleys (flavors): the large- n_v limit
not more than one interaction per loop
 in the large n_v limit

Alex Punnoose & A.F. ,
 Science **310**, 429 (2005)

screening makes the bare value of γ_2 to scale as $1/(2n_v)$

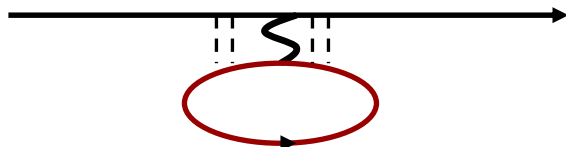
Natural variables: $t = n_v \rho$ and $\theta_2 = 2n_v \gamma_2$

resistance per species

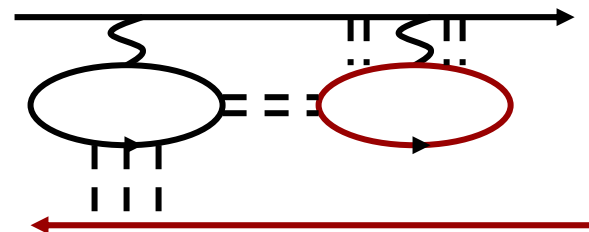
screened interaction has to be **compensated**
 by the loop summation; **each loop involves**
a sum over the spin and valley indices

The limit $n_v \rightarrow \infty$ is taken keeping t and θ_2 finite

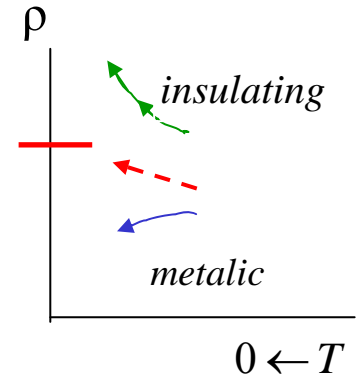
one loop $\Rightarrow \sum_{spin+valleys} \Rightarrow 2n_v t \gamma_2 = t \theta_2$



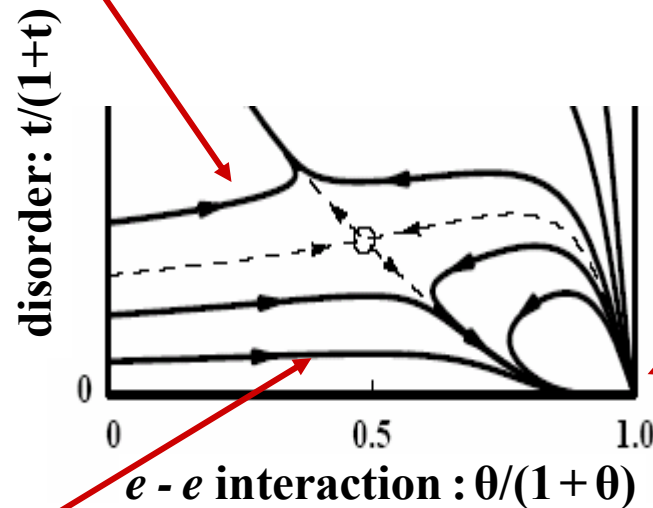
two loops $\Rightarrow t^2 (2n_v \gamma)^2 = t^2 \theta^2$



MIT for interacting electrons in $d=2$:
a **competition** between disorder and
 $e-e$ interactions



disorder takes over



(the strong coupling corner
is not relevant for the MIT)

metallic phase stabilized
by $e-e$ interaction

Experimental determination of the interaction strength

C_{ee} reflects the strength of the spin-related interactions

$$\Delta\sigma(B_{\parallel}, T) = - \left(\frac{e^2}{\pi h} \right) n_v^2 C_{ee}(\gamma_2; \rho) \left(\frac{g\mu_B B_{\parallel}}{k_B T} \right)^2$$

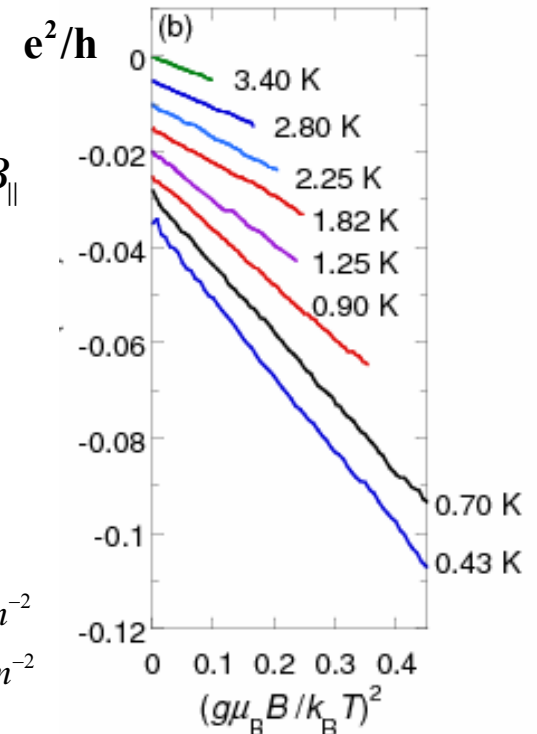
in the small- ρ limit, but still with γ_2 modified by the RG flow:

$$C_{ee} = 0.091 \gamma_2(1+\gamma_2), \text{ where } \gamma_2 = \gamma_2(T)$$

$$kT \gg g\mu_B B_{\parallel}$$

$$n \approx 0.9 \times 10^{11} \text{ cm}^{-2}$$

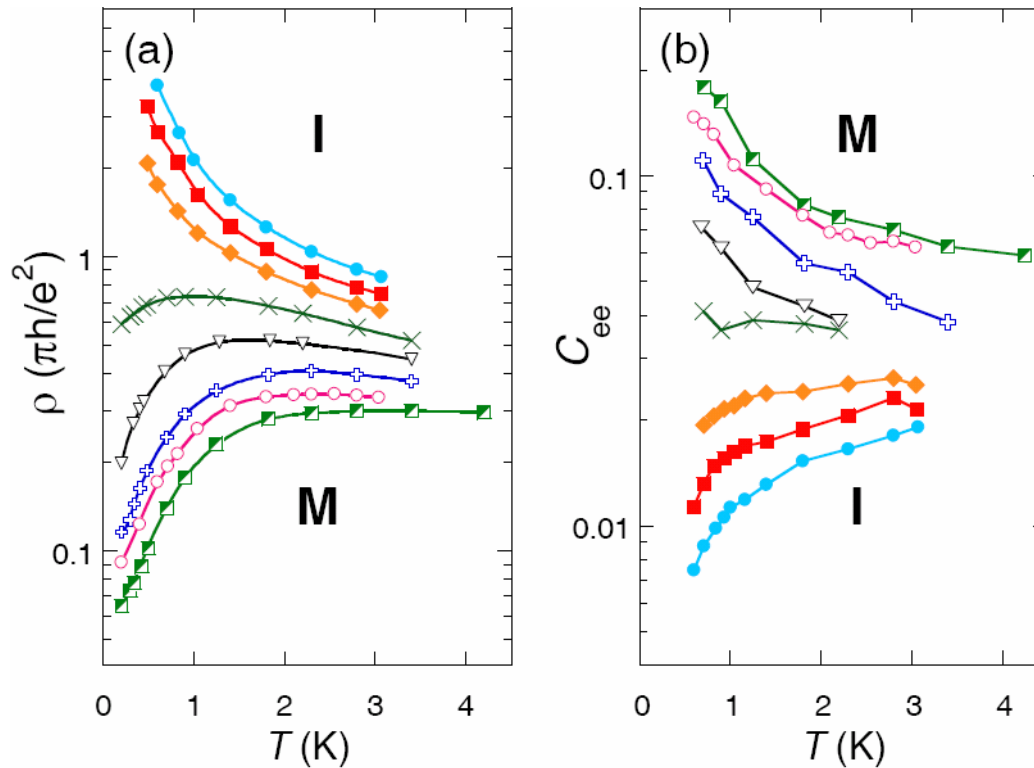
$$n_c \approx 0.8 \times 10^{11} \text{ cm}^{-2}$$



The parameter $C_{ee}(T)$ is given by the slope

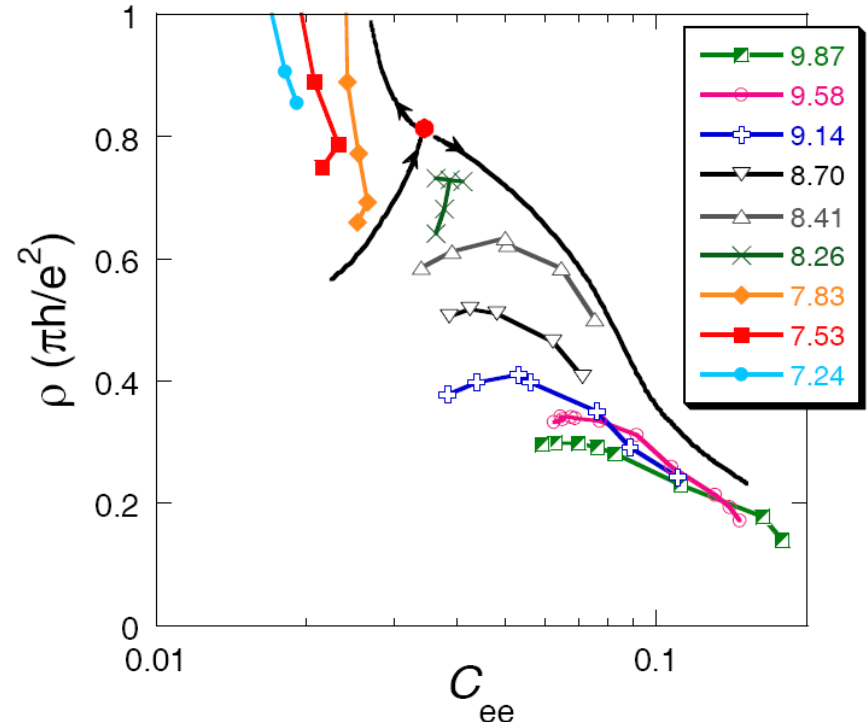
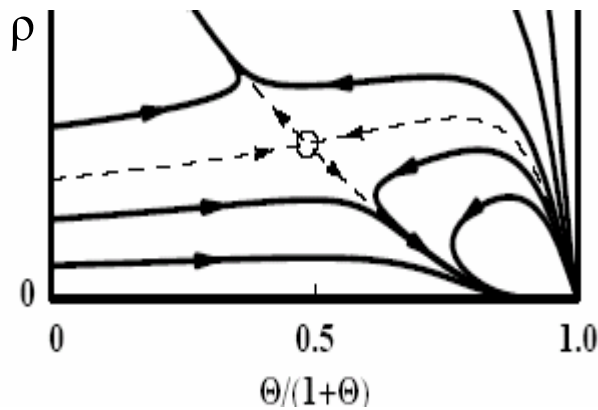
Experimental determination of the interaction strength (cont.)

Both $\rho(T)$ and $C_{ee}(T)$ display fan-like spread across the MIT



First observation of the scale dependence of the effective interaction strength

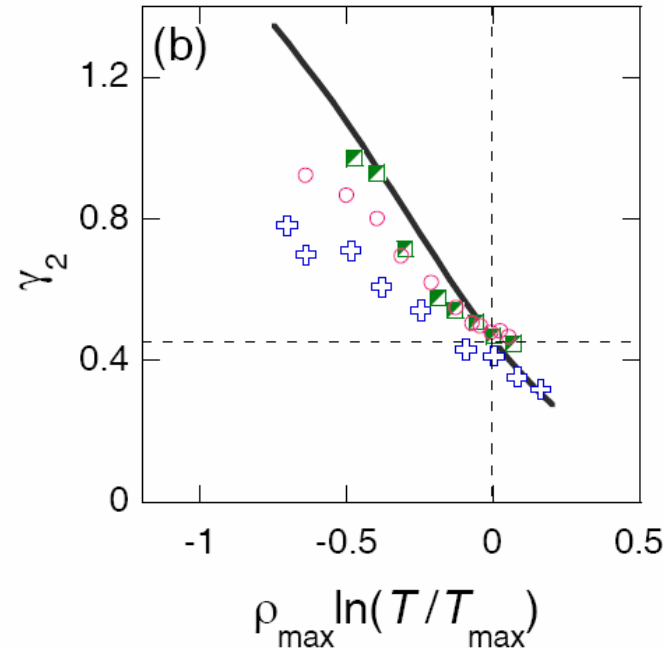
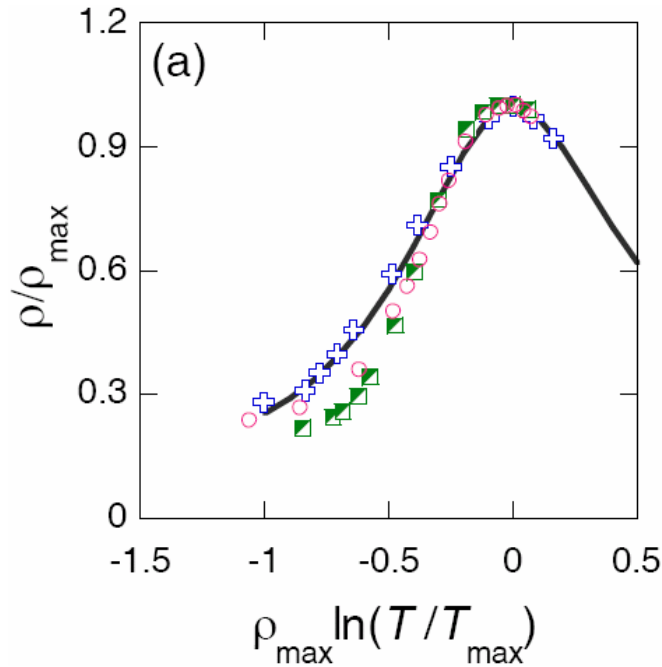
Flow Diagram and Quantum Critical Behavior of the Metal-Insulator Transition in 2D



The disorder-interaction flow diagram of the 2D electron liquid in Si-MOSFETs. The red dot at $\rho_c=0.8$ and $C_{ee}=0.035$ indicates the location of the QCP from which the three separatrices (black lines) emanate. Arrows indicate the direction of the flow as the temperature is lowered. **Only $T>0.5$ data have been used in order to preserve the valley degeneracy.**

Quantitative comparison in the region of small resistance (one-loop)

$$C_{ee} = 0.091 \gamma_2(1+\gamma_2)$$



nearly optimal value of the **bare** values of the amplitude of the e-e interaction

1. Data from region $\rho_{\max} < 0.4$ ($\pi h/e^2$)
2. $\gamma_2(T_{\max}) = 0.45$ ($\gamma_2^* = 2.08$ for the case of a single valley)
3. **No adjustable parameters**

Punnoose & Finkel'stein (2002)
Anissimova, Kravchenko, Punnoose, Finkel'stein & Klapwijk (2007)
 also *Pudalov's group & Burmistrov and Chtchelkatchev*

Further Continuation

non-linear σ - model with e - e interactions

A. Finkel'stein (83)

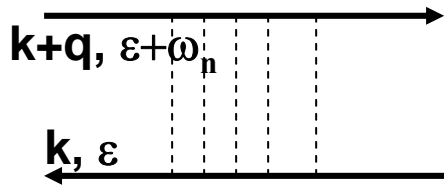
$$S[Q] = \frac{\pi V}{4} \int \text{Tr} \left[D(\vec{\nabla} Q)^2 - 4z \text{Tr}(\hat{\varepsilon} Q) + Q(\hat{\Gamma}_s + \hat{\Gamma}_t + \hat{\Gamma}_c)Q \right] d^2 r$$

$$Q_{nm}^{\alpha\beta ij} \quad \text{Tr} Q = 0 \quad Q^2 = I$$

one more RG-equation: $\frac{d \ln z}{d \xi} = \zeta(t, \Theta)$

The parameter z describes
the renormalization of the DOS of the diffusion modes

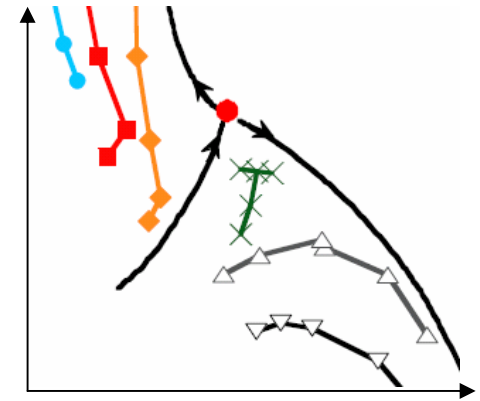
**Physical consequence of the existence of the fixed point:
thermodynamics at MIT have a critical behavior**



$$\approx \frac{1}{Dq^2 + z\omega_n}$$

$$\frac{d \ln z}{d\xi} = \zeta(t, \Theta)$$

$$z = 1/T^{\zeta_c}$$



At the transition:

$$\zeta_c = \zeta(t_c, \Theta_c) \approx 1/4$$

The parameter z corresponds to the effective DOS of the diffusion modes

Specific heat: $C_v \sim (zv)T \sim T^{1-\zeta_c}$

Spin susceptibility: $\chi / \chi_0 = z(1 + \gamma_2) \sim 1/T^{\zeta_c}$

Disordered Fermi-Liquid : leading order in $(1/\varepsilon_F\tau) \ll 1$

$$\tau^{-1} \equiv \tau_{\text{elast}}^{-1}$$

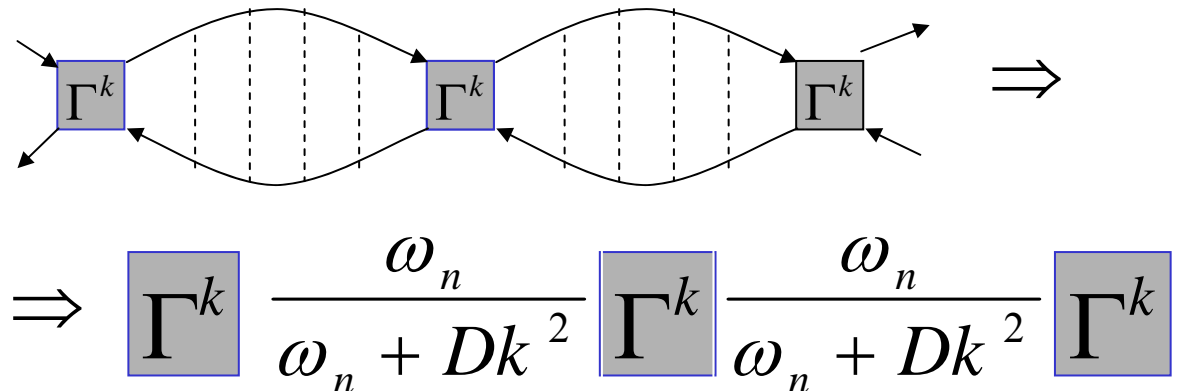
$\tau^{-1} \gg \varepsilon$ (plane waves are not eigenstates anymore)

multiple rescattering of pairs of quasiparticles (each time two into two) should be modified by **diffusion**:

$$\left(\frac{\omega}{\omega - \vec{v} \cdot \vec{k}} \right)_{\text{clean}} \Rightarrow \left(\frac{\omega_n}{\omega_n + Dk^2} \right)_{\text{disorder}}$$

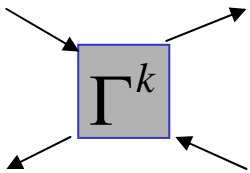
Static amplitudes remain unchanged in the leading order $(1/\varepsilon_F\tau) \ll 1$

dynamic amplitude of scattering in the particle-hole channel; only $l=0$ harmonic is relevant

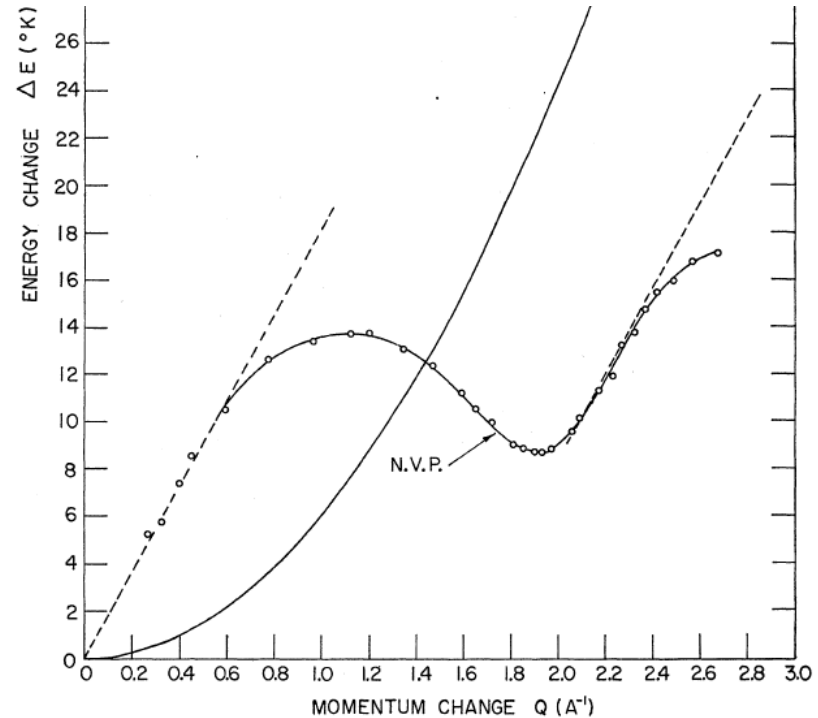


$$\Rightarrow \Gamma^k \frac{\omega_n}{\omega_n + Dk^2} \Gamma^k \frac{\omega_n}{\omega_n + Dk^2} \Gamma^k$$

$$g^*/g_0 = \frac{1}{1 + F_0^\sigma} \approx 1.5 \quad m^*/m \approx 3$$



$$E_{\text{kin}} \gg 1/\tau_{tr}$$



The dispersion curve in liquid He obtained by inelastic neutron scattering, 1961.

(The roton minimum as an illustration of enhancement of the effective mass in the electron liquid with large r_s .)

The enhancement is due to trapping of an electron by its neighbors. Although the mode softens, the energy of the internal motion increases.

Conclusions

- The interplay of interactions and disorder fundamentally **revises** the common belief that 2D electron systems become insulating at low enough temperatures;
- **theory:** Using a **large-N** approximation scheme (valleys), we obtained a two-parameter scaling theory that exhibits a **metal-insulator transition in 2d**. The transition between the metallic and insulating phases is controlled by a finite-resistance **unstable fixed point**. The theory is internally consistent: there are no divergences in the interaction amplitude at a finite temperature.
- **experiment:** **Both** the resistance and the effective interactions are scale (temperature) dependent. Not only resistance but also the interaction amplitude exhibit a **fan-like spread** as the MIT is crossed. Resistance-interaction flow diagram clearly reveals a **quantum critical point**.
- The metallic side of the diagram is accurately described by the theory.
my personal opinion: dilute electron liquid in Si-MOSFETs has been predestined to check the RG-theory in the disordered Fermi liquid.

apparent:

1 clearly seen or understood: *It was apparent for all of us*

~~2 appearing but not necessary true or genuine: *the apparent cause but not the real one*~~

A.S. Hornby, Oxford Student's Dictionary of Current **Physics**